

# Planar Symmetric Pattern Generation

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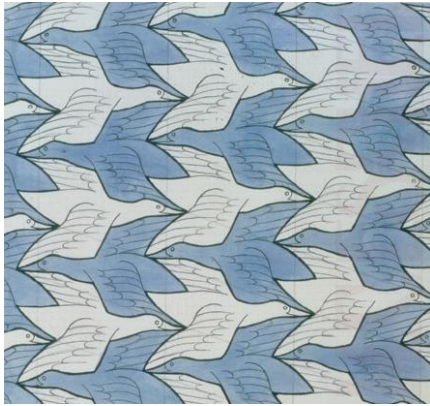
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2026/6/9

# Symmetry in Manufacturing [1-4]

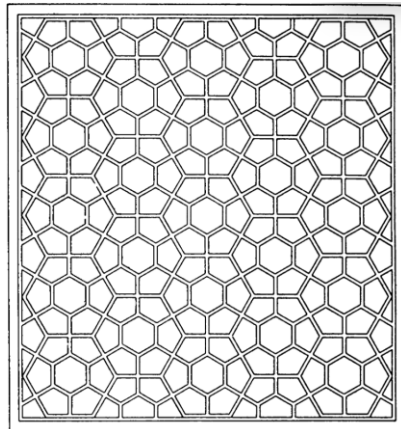
**Periodic Drawing**



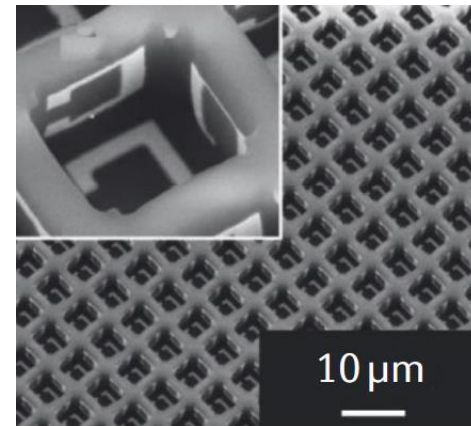
**Chinese Paper-cutting**



**Chinese Window Lattice**



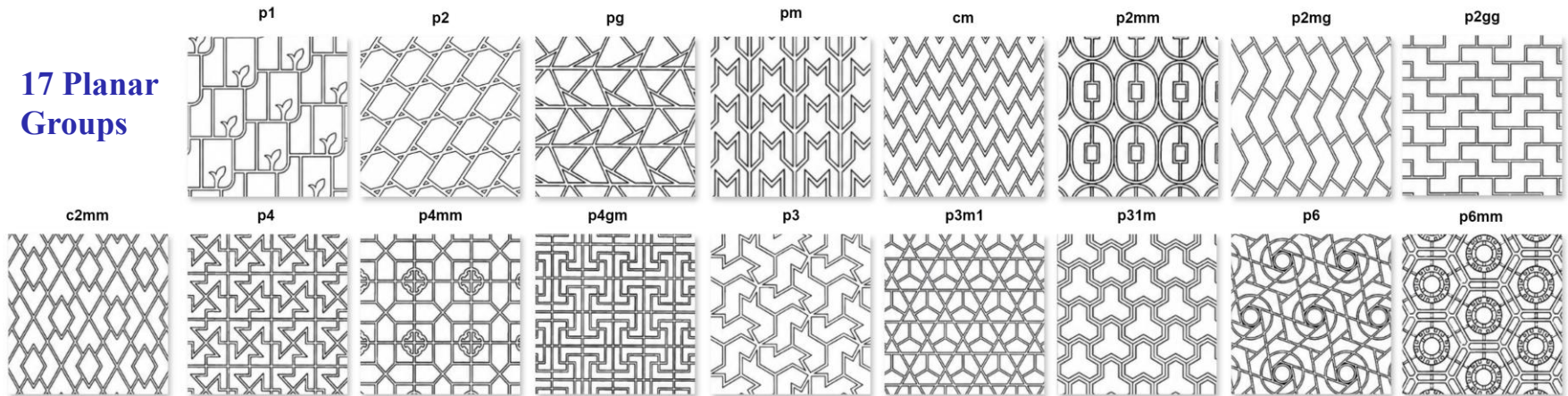
**Metamaterial**



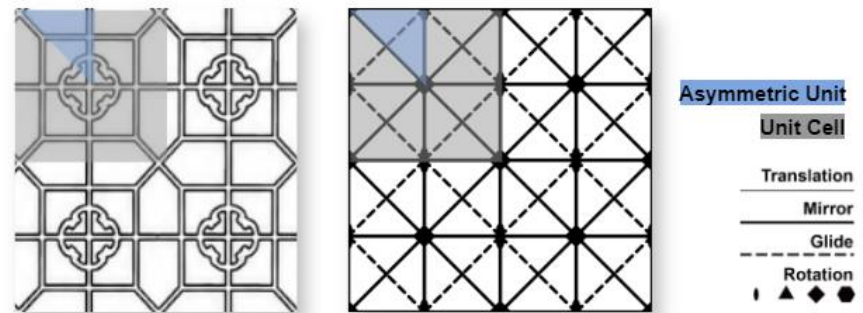
# Planar Group Symmetry [5]

**Planar group:** a planar group is a discrete subgroup of planar Euclidean group that contains two linearly independent translations.

## 17 Planar Groups

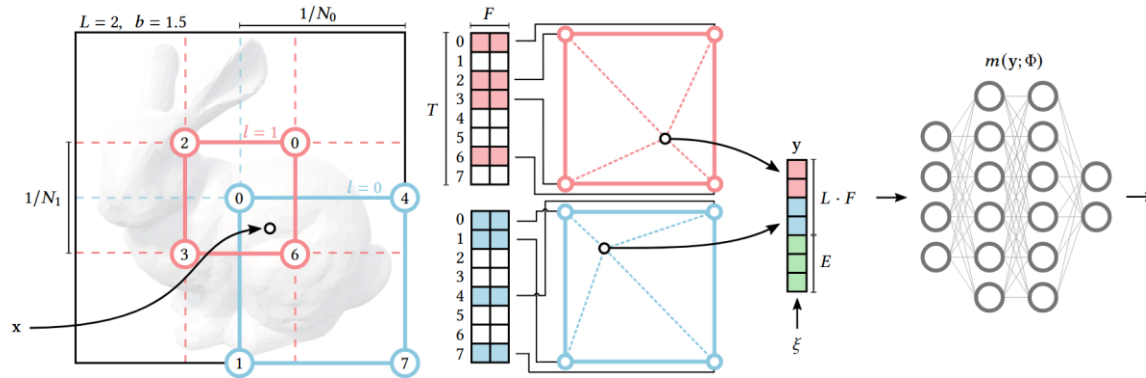


**Asymmetric unit:** the minimal, non-redundant subset of plane from which the structure is obtained through the symmetry operations of the group.

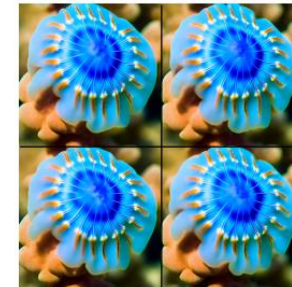
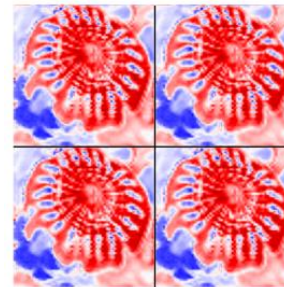
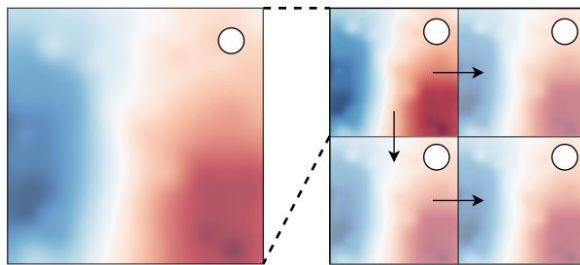


# Symmetry Representation [6]

**2D representation:** Continuous representations play an important role in modeling 3D and 2D objects.



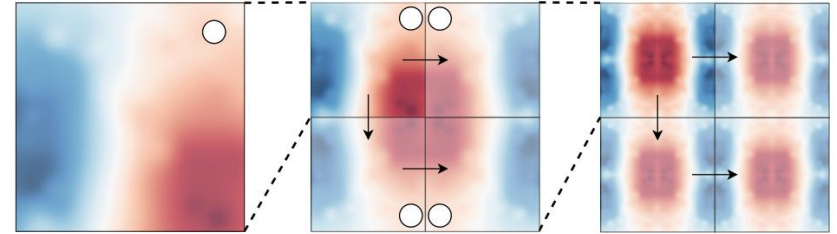
**Naive symmetrization:** Naive extension of continuous representation on asymmetric unit may introduce seams near boundaries.



# Observation

## Fact 1 (reflection preserves continuity):

For affine reflection groups, the extension strategy preserves boundary continuity.



**Fact 2 (decomposition for  $p1$  cases):** Periodic function can be decomposed into a combination of high-symmetry coefficients and low-symmetry bases.

### Planar Fourier Series

$$f(x, y) = \sum_{h, k \in \mathbb{Z}} c_{hk} e^{i(hx + ky)}$$

### Euler Formula



### Basis Function

$$\begin{cases} \cos(hx) \cos(ky) & h \geq 0, k \geq 0 \\ \cos(hx) \sin(ky) & h \geq 0, k > 0 \\ \sin(hx) \cos(ky) & h > 0, k \geq 0 \\ \sin(hx) \sin(ky) & h > 0, k > 0 \end{cases}$$



### Expanded Function

$$\begin{cases} T_h(\cos x) T_k(\cos y) & h \geq 0, k \geq 0 \\ T_h(\cos x) U_{k-1}(\cos y) \sin y & h \geq 0, k > 0 \\ U_{h-1}(\cos x) T_k(\cos y) \sin x & h > 0, k \geq 0 \\ U_{h-1}(\cos x) U_{k-1}(\cos y) \sin x \sin y & h > 0, k > 0 \end{cases}$$

### Multiple-angle Formula

$$\begin{cases} \sin(nx) = U_{n-1}(\cos x) \sin x \\ \cos(nx) = T_n(\cos x) \end{cases}$$

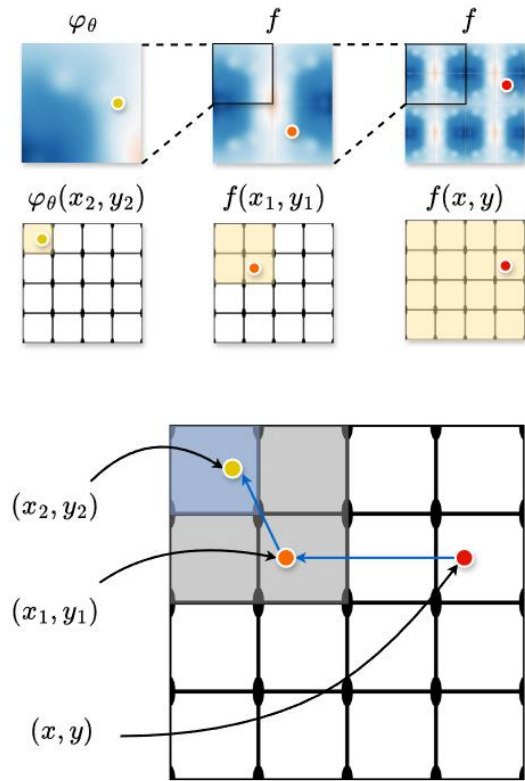
### Decomposition

$$f(x, y) = \sum_{i=1}^4 \underbrace{p_i(\cos x, \cos y)}_{\substack{\text{polynomial of cosine} \\ p2mm \text{ invariant}}} \underbrace{\eta_i(x, y)}_{\substack{1, \sin x, \sin y, \sin x \sin y \\ p1 \text{ invariant}}}$$



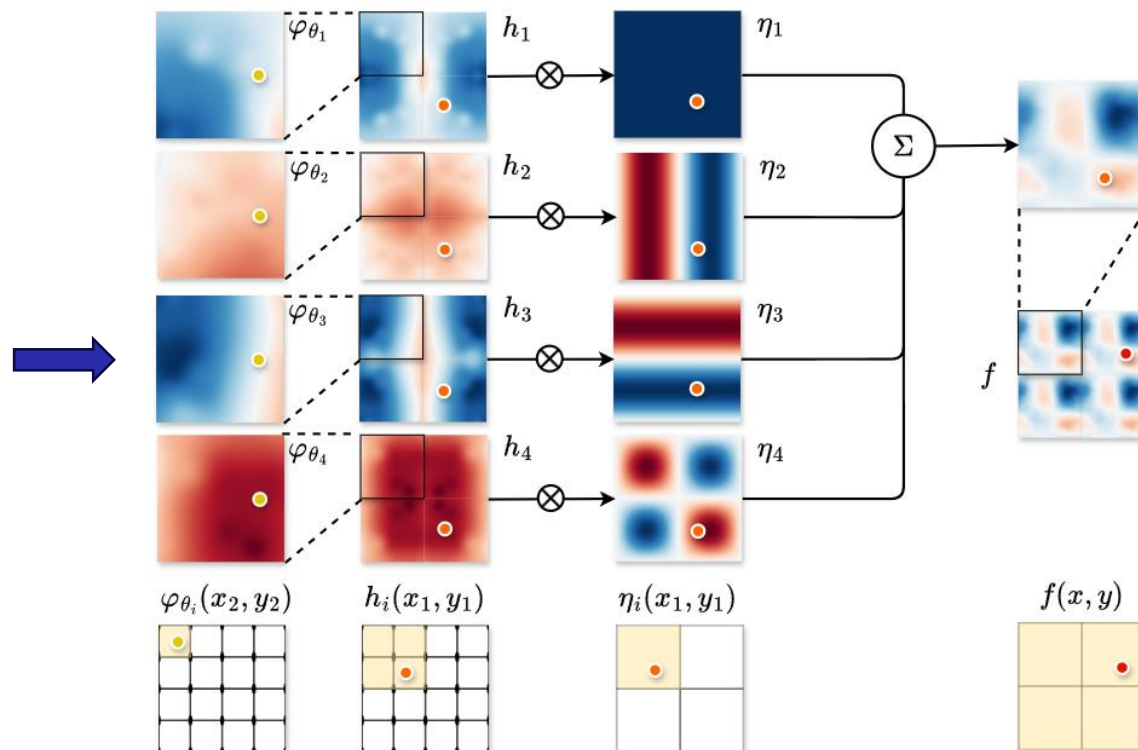
# Symmetrization for $p1$ Case

**Continuous symmetrization for affine reflection groups ( $p2mm$  cases):**



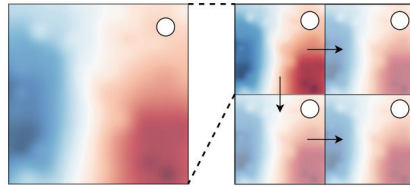
**Continuous symmetrization for  $p1$  case:**

$$f(x, y) = \sum_{i=1}^4 \underbrace{h_i(x, y)}_{\substack{\text{high-symmetry coefficients} \\ p2mm \text{ invariant}}} \underbrace{\eta_i(x, y)}_{\substack{\text{low-symmetry bases} \\ p1 \text{ invariant}}}$$

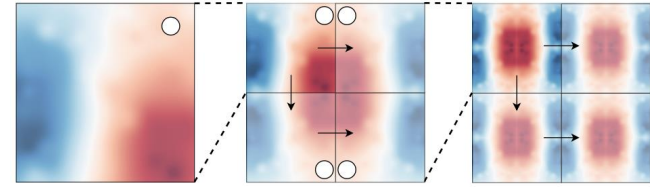


# Key Questions

(1) Extension break continuity

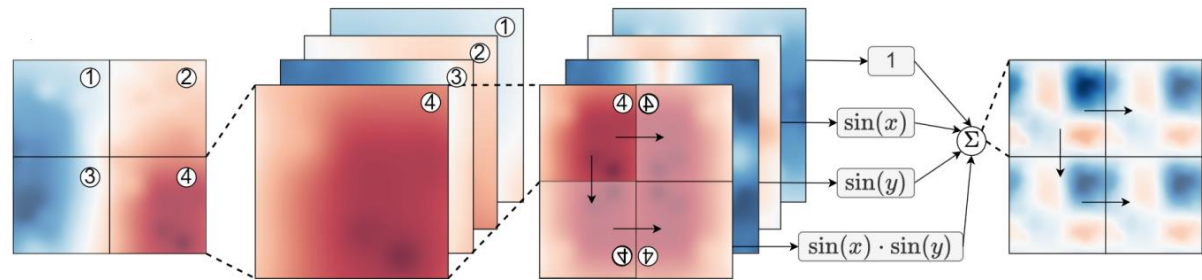


(2) Reflection preserve continuity



## Motivation:

(3) Combination of extension with reflection and bases give continuous symmetry



**Key questions:** To generalize this method to arbitrary planar groups via representation of affine reflection groups, we address the following key questions:

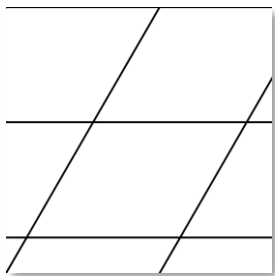
- **Existence of higher symmetry:** For any planar group, does there always exist an affine reflection group serving as a **higher symmetry**?
- **Existence of decomposition:** If exists, does the **decomposition** into high-symmetry coefficients and low-symmetry bases hold for any continuous function?
- **Computation of bases:** How do we explicitly **compute** the low-symmetry bases?

# Existence of higher Symmetry

**Counterexample (constraint of reflection symmetry):** A generic parallelogram lattice cannot support higher affine reflection group symmetry.

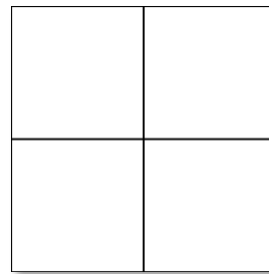
**Extension up to conjugation:**

**Theorem.** Any planar group  $G$  is conjugate to a subgroup of some affine reflection group  $W_a$ , i.e., there exists  $A \in GL(2)$  such that  $AGA^{-1} \subseteq W_a$ .



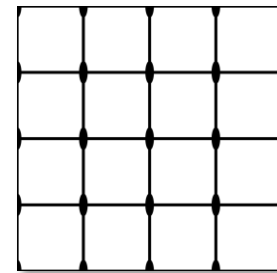
**p1**  
(Oblique Lattice)

**Transformation**  
→



**p1**  
(Rectangular Lattice)

**Extension**  
→



**p2mm**  
(Rectangular Lattice)

**Answer:**

- Q1: For any planar group, does there always exist an affine reflection group serving as a higher symmetry?
- **A1: Yes, up to conjugation by an invertible linear transformation.**

# Existence of Decomposition

**Difficult of the problem:** Due to the algebraic structure of continuous functions, the existence of exact decomposition of continuous function is hard to answer.

## Approximation Theorem:

**Theorem.** Let  $r = [W_a : G]$ , and let  $\Omega$  denote the unit cell. Then there exist  $r$  fixed  $G$ -invariant bases  $\eta_1, \dots, \eta_r$  such that for any  $f \in C_G(\mathbb{R}^2)$  and any  $\epsilon > 0$ , there exist  $h_1, \dots, h_r \in C_{W_a}(\mathbb{R}^2)$  satisfying

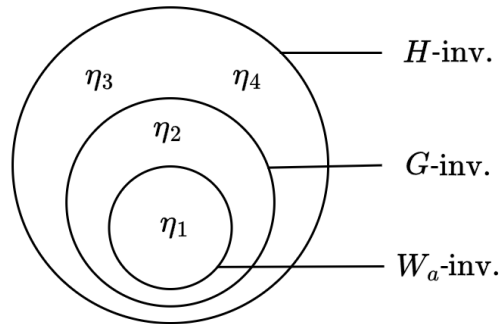
$$\int_{\Omega} \left| f(\mathbf{x}) - \sum_{i=1}^r h_i(\mathbf{x}) \eta_i(\mathbf{x}) \right| d\mathbf{x} < \epsilon.$$

## Answer:

- Q2: Does the decomposition into high-symmetry coefficients and a low-symmetry bases always hold for any continuous function?
- **A2: Yes, in the sense of approximation.**

# Computation of Bases [7]

**Computation using existing results:** Result of symmmorphic planar groups can be found in [Kim et al.](#)



$$H \subset G \subset W_a, [G : H] = 2$$

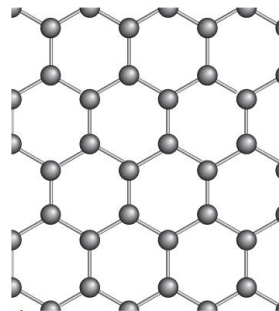
Lattice	$G$	$W_a$	$\mathbf{a}$	$\mathbf{b}$	$\eta_2$	$\eta_3$	$\eta_4$	$r$
Oblique	$p1$		$\mathbf{a}$	$\mathbf{b}$	$s_1$	$s_2$	$s_1 s_2$	4
Oblique	$p2$		$\mathbf{a}$	$\mathbf{b}$	$s_1 s_2$	—	—	2
Rectangular	$pm$		$\mathbf{a}$	$\mathbf{b}$	$s_1$	—	—	2
Rectangular	$pg$		$\mathbf{a}$	$\mathbf{b}/2$	$s_1 c_2$	$s_1 s_2$	$c_2 s_2$	4
Rectangular	$cm$	$p2mm$	$\mathbf{a}/2$	$\mathbf{b}/2$	$c_1 c_2$	$c_1 s_2$	$c_2 s_2$	4
Rectangular	$p2mm$		$\mathbf{a}$	$\mathbf{b}$	—	—	—	1
Rectangular	$p2mg$		$\mathbf{a}/2$	$\mathbf{b}$	$s_1 s_2$	—	—	2
Rectangular	$p2gg$		$\mathbf{a}/2$	$\mathbf{b}/2$	$c_1 c_2$	$c_1 s_1 s_2$	$s_1 c_2 s_2$	4
Rectangular	$c2mm$		$\mathbf{a}/2$	$\mathbf{b}/2$	$c_1 c_2$	—	—	2
Square	$p4$		$\mathbf{a}$	$\mathbf{b}$	$(c_1 - c_2)s_1 s_2$	—	—	2
Square	$p4gm$	$p4mm$	$\mathbf{a}/2$	$\mathbf{b}/2$	$c_1 c_2$	$(c_1 - c_2)s_1 s_2$	$(c_1 - c_2)c_1 c_2 s_1 s_2$	4
Square	$p4mm$		$\mathbf{a}$	$\mathbf{b}$	—	—	—	1
Hexagonal	$p3$		$\mathbf{a}$	$\mathbf{b}$	$\phi_1^{-+}$	$\phi_2^{--}$	$\phi_3^{+-} = \phi_1^{-+} \phi_2^{--}$	4
Hexagonal	$p3m1$		$\mathbf{a}$	$\mathbf{b}$	$\phi_1^{-+}$	—	—	2
Hexagonal	$p31m$	$p6mm$	$\mathbf{a}$	$\mathbf{b}$	$\phi_2^{--}$	—	—	2
Hexagonal	$p6$		$\mathbf{a}$	$\mathbf{b}$	$\phi_3^{+-}$	—	—	2
Hexagonal	$p6mm$		$\mathbf{a}$	$\mathbf{b}$	—	—	—	1

**Answer:**

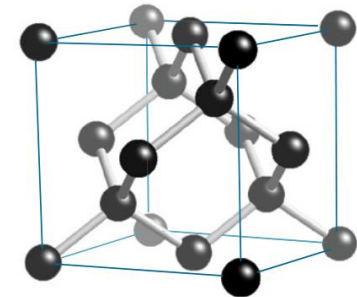
- Q3: How do we explicitly compute the low-symmetry bases?
- **A3: By look up the table.**

# Extension to $n$ -Dimensional Space [8]

**Crystallographic groups:** a crystallographic group is a discrete subgroup of  $n$ -dimensional Euclidean group that contains  $n$  linearly independent translations.



Graphite ( $n = 2$ )  
Planar Group  $p6mm$



Diamond ( $n = 3$ )  
Space Group  $Fd\bar{3}m$

## Answer to key questions:

- Q1: For any crystallographic group, does there always exist an affine reflection group serving as a higher symmetry?
- **A1: Yes (up to conjugation), if  $n \leq 3$ ; no, if  $n > 3$ .**
- Q2: Does the decomposition into high-symmetry coefficients and a low-symmetry bases always hold for any continuous function?
- **A2: No; but yes (in the sense of approximation), if the crystallographic group is conjugate to a subgroup of an affine reflection group (e.g.  $n \leq 3$ ).**
- Q3 (open): How do we explicitly compute the low-symmetry bases?

# Generation with Physical Constraint

**Pattern design (visual semantic constraints):** symmetric images that align with given text.

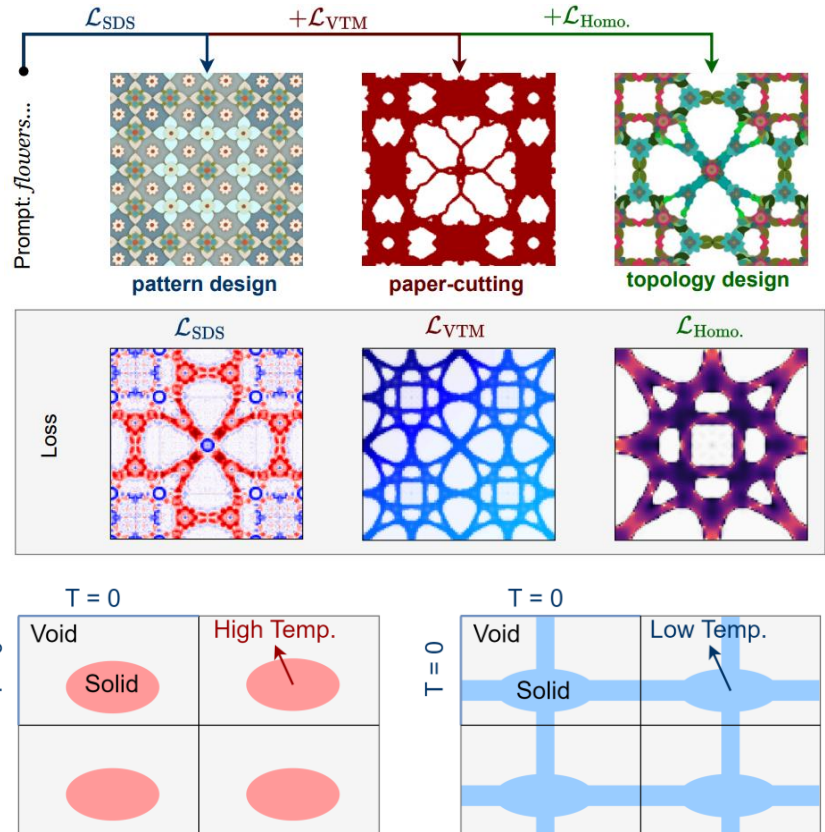
$$\nabla_{\theta} \mathcal{L}_{\text{SDS}} \propto \mathbb{E}_{t, \epsilon} [(\hat{\epsilon}_{\phi}(z_t, t, y) - \epsilon) \nabla_{\theta} z_{\theta}]$$

**Paper-cutting design (visual + connectivity constraints):** connected, symmetric binary masks subject to volume and text constraints.

$$\mathcal{L}_{\text{VTM}} = \left( \frac{1}{|\Omega|} \int_{\Omega} t(\rho_{\theta})(\mathbf{x})^p d\mathbf{x} \right)^{1/p}$$

$$\mathcal{L}_{\text{vol}} = \left( \frac{1}{|\Omega|} \int_{\Omega} \rho_{\theta} d\mathbf{x} - \rho_0 \right)^2$$

**Topology Design (visual + connectivity + mechanical constraints):** Generating connected, symmetric binary masks subject to volume and mechanical constraints, alongside text-aligned images.

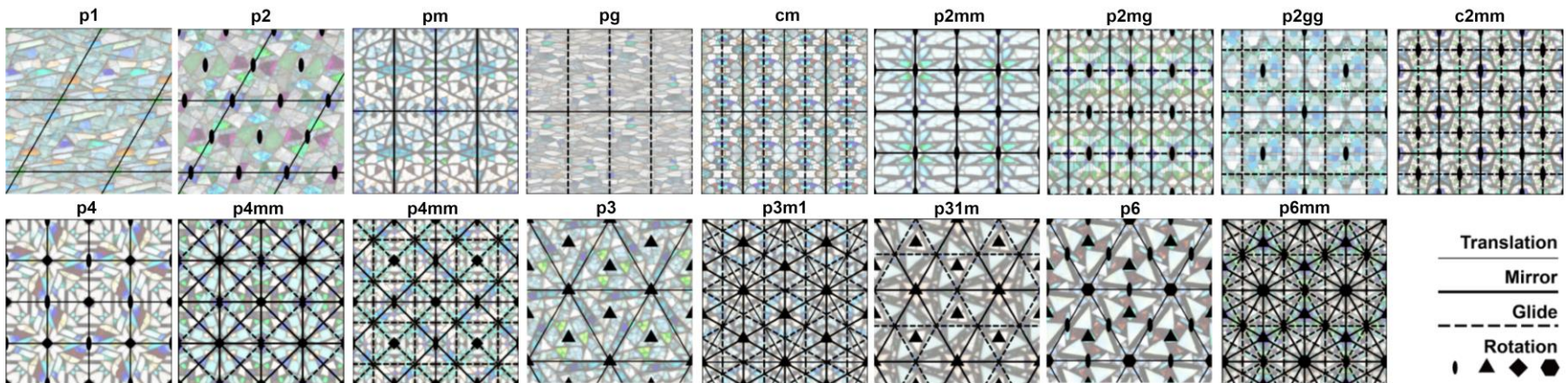


$$\mathcal{L}_{\text{Homo}} = -c(\rho_{\theta})$$

$$c = E_{11}^H + E_{12}^H + E_{21}^H + E_{22}^H$$

# Experiment: Pattern Design

**Visualization:** 1 prompt (*stained-glass mosaic fragments...*), 17 planar groups



## Comparison with other symmetrization:

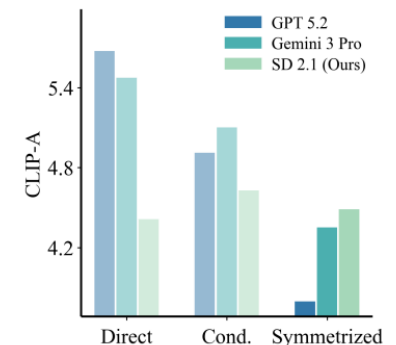
17 prompts, same planar group

## Comparison with text-conditioned generation:

17 prompts, 17 planar groups

- **Direct Generation:** Models generate images directly from the text
- **Conditional Generation:** Generate images with symmetry control
- **Post-Symmetrization:** Fit images with symmetric parameterization using MSE loss

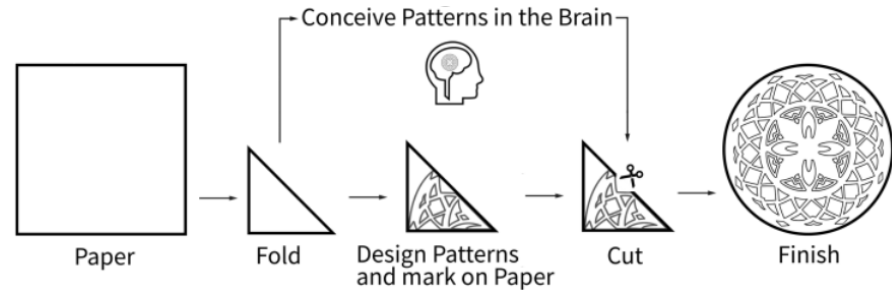
Method	$n = 64$	$n = 128$	$n = 256$
BP ( $\alpha = 0.25$ )	3.81	3.07	3.46
BP ( $\alpha = 0.50$ )	3.98	3.38	3.61
BP ( $\alpha = 1.00$ )	4.05	3.42	3.48
Ours	<b>4.30</b>	<b>4.20</b>	<b>3.99</b>



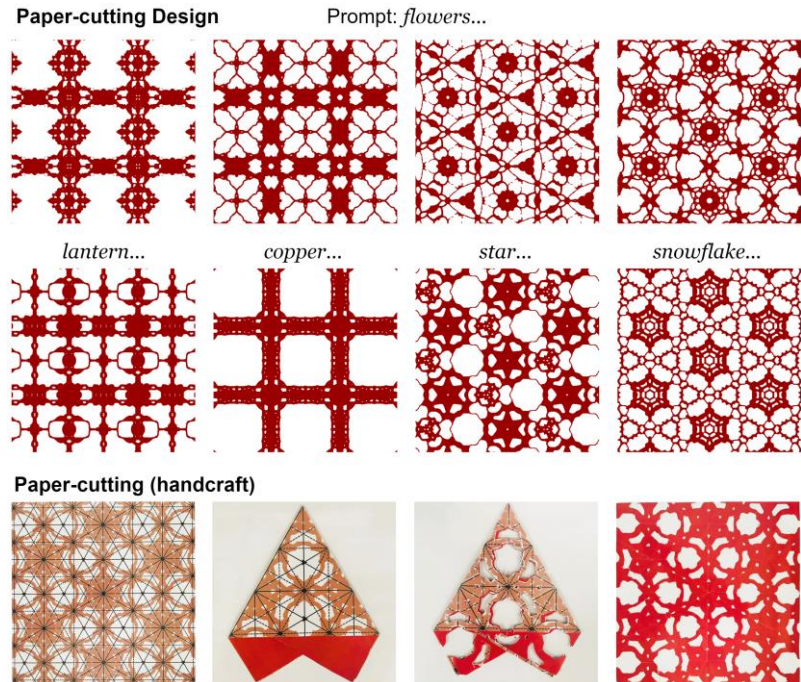
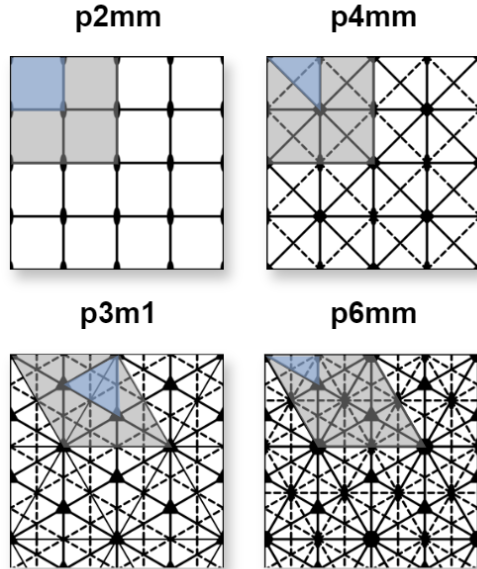
# Experiment: Paper-Cutting Design [9]

## Paper-cutting design:

- 1 prompt, 4 planar groups
- 4 prompts, 4 planar groups
- Handcraft



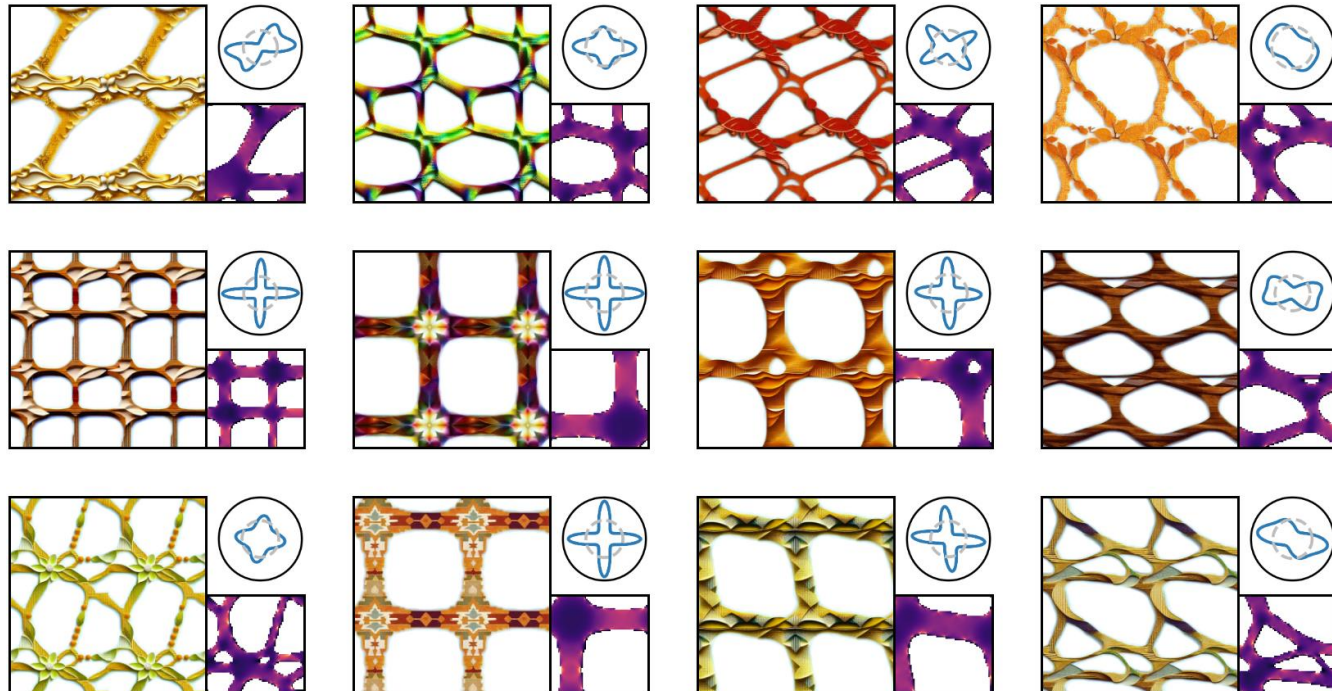
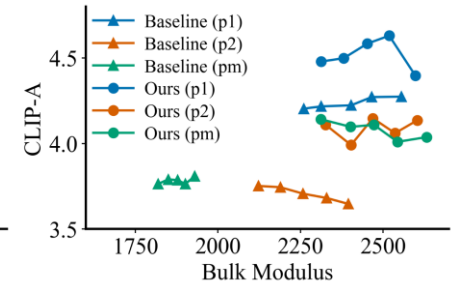
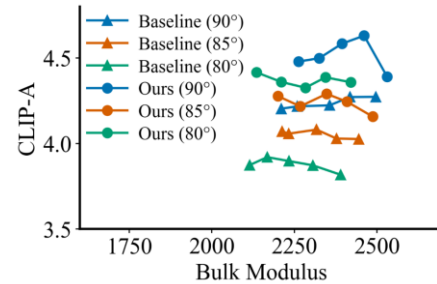
## Planar Affine Reflection Group



# Experiment: Topology Design

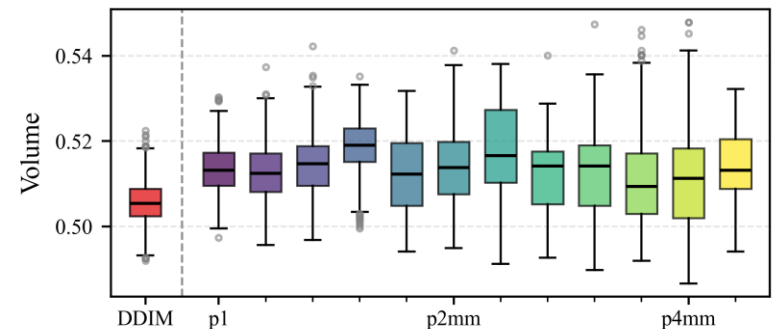
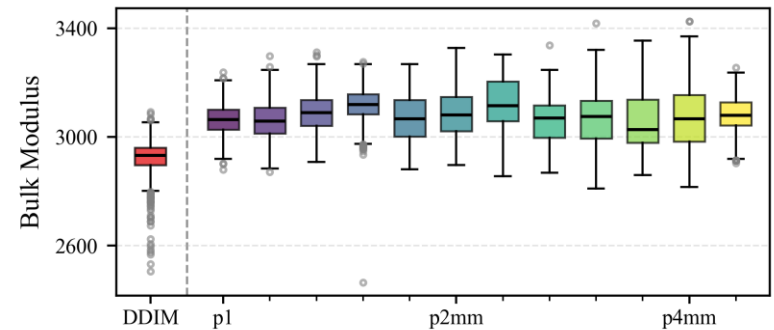
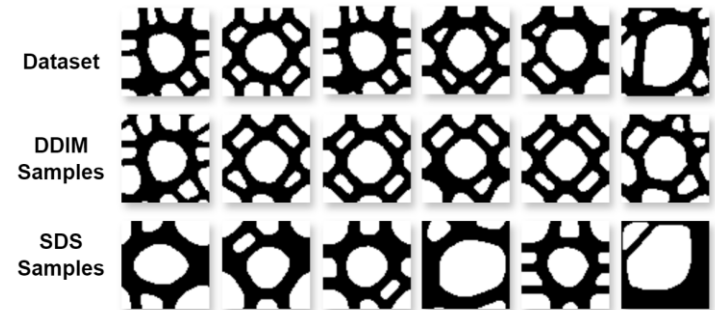
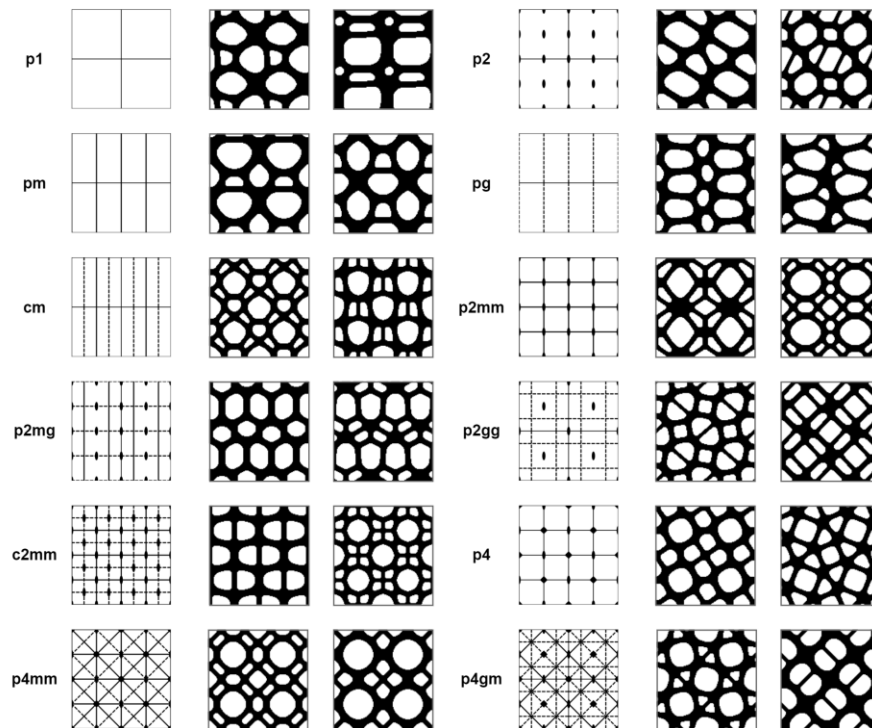
## Topology design (comparison with other loss design): 12 prompts

- Differ planar groups
- Same planar groups, differ lattice



# Experiment: Metamaterial Design

**Zero-shot generation:** Generate symmetric binary mask with pretrained diffusion model and SDS loss (similar to pattern design).



# Reference

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[www.mcescher.com](http://www.mcescher.com)
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- [9] Liu, Lijuan, Yang Chen, Pinhao Wang, et al. 2018. "Papercut: Digital Fabrication and Design for Paper Cutting." *Extended Abstracts of the 2018 CHI Conference on Human Factors in Computing Systems* (New York, NY, USA), CHI EA '18, April 20, 1–6.